IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Stefan Groetsch

Art Unit : Unknown

Serial No.: To Be Assigned

Examiner: Unknown

Filed

: Herewith

Title

: SEMICONDUCTOR DEVICE WITH A COOLING ELEMENT

Mail Stop PCT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

<u>INFORMATION</u> DISCLOSURE STATEMENT

Applicants request consideration of the references listed on the attached PTO-1449 form. Under 37 C.F.R. § 1.98 (a)(2)(ii), only copies of foreign patent documents and/or non-patent literature are enclosed. Copies of any listed U.S. patents or U.S. patent application publications can be provided upon request.

This statement is being filed with the application. Please apply any charges or credits to Deposit Account No. 06-1050.

Respectfully submitted,

Marc M. Wefers* for

Alan D. Smith Reg. No. 32,005

*See attached document certifying that Marc M. Wefers has limited recognition to practice before the U.S. Patent and Trademark Office under 37 C.F.R. § 11.9(b).

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Substitute Form PTO-1449 (Modified)

U.S. Department of Commerce Patent and Trademark Office Attorney's Docket No. 12406-109US1

Information Disclosure Statement by Applicant (Use several sheets if necessary)

Applicant

Stefan Groetsch

Filing Date Herewith Group Art Unit

(37 CFR §1.98(b))

	U.S. Patent Documents						
Examiner Initial	Desig. ID	Document Number	Publication Date	Patentee	Class	Subclass	Filing Date If Appropriate
	AA	5,105,430	04/14/1992	Mundinger et al.			
	AB	5,373,731	12/20/1994	Tanaka, et al.			
	AC	5,812,570	09/22/1998	Spaeth			
	AD	5,903,583	05/11/1999	Ullman et al.			
	AE	US2002/0063 329	05/30/2002	Horie et al.			
	AF	US2003/0099 267	0529/2003	Henning et al.			
	AG						
	AH						
	AI						
	AJ						
	AK						

Foreign Patent Documents or Published Foreign Patent Applications								
Examiner	Desig.	Document	Publication	Country or			Translation	1
Initial	ID	Number	Date	Patent Office	Class	Subclass	Yes	No
	AL	DE 4315580	11/17/1993	Germany			Abstract	
	AM	DE 4335512	06/01/1995	Germany			Abstract	
	AN	DE 19605302	02/14/1996	Germany			Abstract	
	AO	DE 19506093	08/29/1996	Germany			Equivalent to 5,903,583	
	AP	DE 19821544	12/16/1999	Germany			Abstract	
	AQ	DE 10061265	06/27/2002	Germany			Equivalent to US 2003/0099267	
••	AR	EP 0 509825	10/21/1992	Europe			Yes	
*p **	AS	EP 0 771604	05/07/1997	Europe			Equivalent to 5,373,731	
	AT	WO 97/30494	08/21/1997	WIPO			Abstract	

Other Documents (include Author, Title, Date, and Place of Publication)					
Examiner Initial	Desig. ID	Document			
Examiner Sign	ature	Date Considered			

EXAMINER: Initials citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

Attorney's Docket No. -Application No. 25 Substitute Form PTO-1449 U.S. Department of Commerce Patent and Trademark Office (Modified) 12406-109US1 Applicant **Information Disclosure Statement** Stefan Groetsch by Applicant (Use several sheets if necessary) Filing Date Group Art Unit Herewith (37 CFR §1.98(b))

Other Documents (include Author, Title, Date, and Place of Publication)				
Examiner Initial	Desig. ID	Document		
	AU	Johnson, WB. et al., "Diamond/Al Metal Matrix Composites Formed by the Pressureless Metal Infiltration Process", J. Mater. Res., Vol. 8, No. 5, pp. 1169-1173, XP-002304359, 1993		
	AV	Kerns, JA. Et al., "Dymalloy: A Composite Substrate for High power Density Electronic Components", <i>The International Journal of Microcircuits and Electronic Packaging</i> , Vol. 19, no. 3, XP 000639483, 1996.		
	AW	Sun, Q. and Inal, QT., "Fabrication and Characterization of Diamond/Copper Composites for Thermal Management Substrate Applications", <i>Materials Science and Engineering</i> , B41, pp. 261-266, 1996.		
	AX			

Examiner Signature

Date Considered

EXAMINER: Initials citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.